# THEORY OF MULTILAYER FILM

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#### THE DESIGN



Nd (neodymium-doped): YAG

λ = 1.064 μm



#### THIN FILM AND INTERFERENCE



Constructive interference:  $\Delta = m\lambda = 2nt$ 

Destructive interference:  $\Delta = (m + \frac{1}{2})\lambda = 2nt$ 



#### TRANSFER MATRIX AND REFLECTION COEFFICIENT



(1)  $r = (\gamma_0 m_{11} + \gamma_0 \gamma_s m_{12} - m_{21} - \gamma_s m_{22})$ 

 $(\gamma_{o} m_{11} + \gamma_{o} \gamma_{s} m_{12} + m_{21} + \gamma_{s} m_{22})$ 

#### **KEY TASK**

#### <u>Assumptions:</u> i) Laser beam is incident normally. ii) Film thickness must be $\lambda/4$ .

1)Determine the refractive indices we need.

2) Determine the corresponding thickness.

#### NAME OF THE GAME

 (normal incidence) (quarter-wave thickness)

(2) 
$$n_2/n_1 = \sqrt{(n_s/n_o)}$$



## CHOOSE COATING MATERIAL

- $\sqrt{(n_s / n_o)} = 1.233$
- [Ge] n<sub>2</sub> = 4



- [Si]  $n_1 = 3.3$
- $(n_2 / n_1) = 1.212$



### DETERMINE FILM THICKNESS

• 
$$\lambda_{\rm f} = \lambda_{\rm o} / n_{\rm f}$$
  $\lambda_{\rm o} = 1.064 \,\mu{\rm m}$ 

• 
$$n_1 = 3.3$$
  $n_2 = 4$ 

• 
$$\lambda_1 = 322.4 \text{ nm}$$
  $\lambda_2 = 266 \text{ nm}$ 

•  $t_1 = 80.6 \text{ nm}$   $t_2 = 66.5 \text{ nm}$ 

#### **REFLECTANCE COMPARISON**

#### <u>R% (double-layer)</u>

<u>R% (mono-layer)</u>

•[Ge / Si ] = .029%

• $[ThO_2 / Al_2O_3] = .038\%$ 

 $\cdot$  [CeF<sub>3</sub> / MgF<sub>2</sub>] = .209%

[SiO] = 5.06%

[Cryolite] = .28%

 $[CeF_3] = 8.03\%$ 

 $\cdot$  [Nd<sub>2</sub>O<sub>3</sub> / Al<sub>2</sub>O<sub>3</sub>] = .041%